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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Crocker et al.

Title:

Nanometer-Scale Engineered Structures, Methods and Apparatus

for Fabrication thereof, and Applications to Mask Repair,

Enhancement, and Fabrication

Appl. No.:

10/689,547

Filing Date:

10/21/2003

Examiner:

Ruggles

Art Unit:

1756

## RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

The Applicants respectfully respond to the Notice of Non-Compliant Amendment, mailed on December 4, 2006.

The amendments to the abstract begin on page 2.